

# PATENT ASSIGNMENT

Electronic Version v1.1

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|---|-------------------------------|
| SUBMISSION TYPE:  | NEW ASSIGNMENT                |
| NATURE OF CONVEYANCE:   | ASSIGNMENT                    |
| <b>CONVEYING PARTY DATA</b>   |                               |
| Name  | Execution Date                |
| Xiaolin Chen  | 05/31/2007                    |
| Srinivas D. Nemani  | 05/31/2007                    |
| Shankar Venkataraman  | 06/11/2007                    |
| <b>RECEIVING PARTY DATA</b>   |                               |
| Name:   | Applied Materials, Inc.       |
| Street Address:   | P. O. Box 450A                |
| City:   | Santa Clara                   |
| State/Country:  | CALIFORNIA                    |
| Postal Code:  | 95052                         |
| <b>PROPERTY NUMBERS Total: 1</b>  |                               |
| Property Type   | Number                        |
| Application Number:   | 11753968                      |
| <b>CORRESPONDENCE DATA</b>  |                               |
| Fax Number:   | (408)986-3090                 |
| <i>Correspondence will be sent via US Mail when the fax attempt is unsuccessful.</i>                    |                               |
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| Correspondent Name:   | Applied Materials             |
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| Address Line 4:   | Santa Clara, CALIFORNIA 95052 |
| ATTORNEY DOCKET NUMBER:   | 10923/HDP/CVD                 |
| NAME OF SUBMITTER:  | Barbara Holt                  |
| <b>Total Attachments: 2</b><br>source=10923 _ASG 071007#page1.tif<br>source=10923 _ASG 071007#page2.tif |                               |

CH \$40.00 11753968

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**PATENT  
REEL: 019544 FRAME: 0063**

**ASSIGNMENT FOR APPLICATION FOR PATENT**

WHEREAS:

Names and Addresses  
of Inventors:

|    |   |    |  |
|----|---|----|--|
| 1) | Xiaolin Chen<br>1552 Chihong Drive<br>San Jose, CA 95131<br>United States               | 2) | Srinivas D. Nemani<br>504 Fern Ridge Court<br>Sunnyvale, CA 94087<br>United States |
| 3) | Shankar Venkataraman<br>3444 Notre Dame Drive<br>Santa Clara, CA 95051<br>United States |    |  |

(hereinafter referred to as Assignors), have invented a certain invention entitled:

**A NOVEL DEPOSITION-PLASMA CURE CYCLE PROCESS TO ENHANCE FILM QUALITY OF  
SILICON DIOXIDE**

for which application for Letters Patent in the United States was filed on May 25, 2007, under  
Application No. 11/753,968, executed on even date herewith; and

WHEREAS, Applied Materials, Inc., a corporation of the State of Delaware, having a place of  
business at 3050 Bowers Avenue, Santa Clara, California 95054 (hereinafter referred to as Assignee), is  
desirous of acquiring the entire right, title and interest in and to said application (hereinafter referred to as  
Application), and the invention disclosed therein (hereinafter referred to as Invention), and in and to all  
embodiments of the Invention, heretofore conceived, made or discovered by said Assignors, and in and to  
any and all patents, inventor's certificates and other forms of protection (hereinafter referred to as Patents)  
thereon granted in any and all countries and groups of countries.

NOW, THEREFORE, in consideration of good and valuable consideration acknowledged by said  
Assignors to have been received in full from said Assignee:

1. Said Assignors hereby sell, assign, transfer and convey to Assignee the full and exclusive  
right, title and interest (a) in and to said Application and said Invention; (b) in and to all rights to apply for  
patents on said Invention in any and all countries pursuant to the International Convention for the  
Protection of Industrial Property or otherwise; (c) in and to any and all Applications filed and any and all  
Patents granted on said Invention in any and all countries and groups of countries, including each and  
every Application filed and each and every Patent granted on any application which is a division,  
substitution, or continuation of said Application; and (d) in and to each and every reissue or extension of  
any of said Patents.

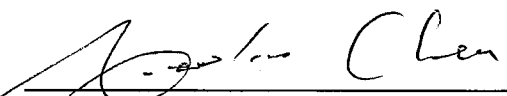
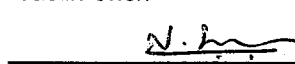

2. Said Assignors hereby covenant and agree to cooperate with said Assignee to enable  
said Assignee to enjoy to the fullest extent the right, title and interest to said Invention herein conveyed in  
any and all countries and groups of countries. Such cooperation by said Assignors shall include prompt  
production of pertinent facts and documents, giving testimony, execution of petitions, oaths, specifications,  
declarations or other papers, and other assistance all to the extent deemed necessary or desirable by said  
Assignee (a) for perfecting in said Assignee the right, title and interest herein conveyed; (b) for  
prosecuting any of said applications; (c) for filing and prosecuting substitute, divisional, continuing or

additional applications covering said Invention; (d) for filing and prosecuting applications for reissuance of any of said Patents; (e) for interference or other priority proceedings involving said Invention; and (f) for legal proceedings involving said Invention and any application therefor and any Patents granted thereon, including without limitation opposition proceedings, cancellation proceedings, priority contests, public use proceedings, infringement actions and court actions; provided, however, that the expense incurred by said Assignors in providing such cooperation shall be paid for by said Assignee.

3. The term and covenants of this agreement shall inure to the benefit of said Assignee, its successors, assigns and other legal representatives, and shall be binding upon said Assignors, their respective heirs, legal representatives and assigns.

4. Said Assignors hereby warrant and represent that they have not entered and will not enter into any assignment, contract, or understanding in conflict herewith.

IN WITNESS WHEREOF, the said Assignors have executed and delivered this instrument to said Assignee on the dates indicated below.

|    |               |        |  |
|----|---------------|--------|--|
| 1) | <u>05/31/</u> | , 2007 | <br>Xiaolin Chen         |
| 2) | <u>05/31/</u> | , 2007 | <br>Srinivas D. Nemani   |
| 3) | <u>6/11</u>   | , 2007 | <br>Shankar Venkataraman |

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